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AUG 17 2005

**METHOD OF FORMING A PHOTO SENSOR ON SEMICONDUCTOR WAFER
WITH OVERLAPPED REGION**

Appl. No. : 10/065,296 Confirmation No. 5720
Applicant : Liang-Hua Lin,
Anchor Chen
Filed : October 1, 2002
TC/A.U. : 2813
Examiner : Erik J Kielin
Docket No. : NAUP0477USA1
Customer No. : 27765

Commissioner for Patents
P.O. Box 1450
Alexandria VA 22313-1450

AMENDMENT

5 Sir:

In response to the Office action of February 16, 2005, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

10 **Remarks/Arguments** begin on page 5 of this paper.